

Docket No.: 49657

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Yoshikazu Nagamura, et al.

Serial No.:

(Divisional of Serial No. 09/504,728)

Group Art Unit:

Filed: February 09, 2001

Examiner:

For: METHOD OF AND APPARATUS FOR WASHING PHOTOMASK AND WASHING
SOLUTION FOR PHOTOMASK

PRELIMINARY AMENDMENT

Commissioner for Patents
Washington, DC 20231

Sir:

Prior to examination of the above-referenced application, please amend the application as follows:

IN THE CLAIMS:

Claim 6, line 2, change "also employing ultrasonics waves in said first step of claim 1" to

--wherein said step of removing organic matter and metal impurities employs ultrasonics waves--

REMARKS

Entry of this preliminary amendment is respectfully requested.

Respectfully submitted,

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